

L Number	Hits	Search Text	DB	Time stamp
2	84	"5354985"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:41
3	114	"5294790" or "5354985"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:41
4	486	waveguide and flying	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:41
5	6	("5294790" or "5354985") and (waveguide and flying)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 10:41
1	41	"5294790"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:13
6	149341	exchang\$5 near5 ion	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:26
7	2450	("near" adj1 field) and optic\$5 and (tip or probe)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:18
8	56	(exchang\$5 near5 ion) and (("near" adj1 field) and optic\$5 and (tip or probe))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:15
9	3170	("near" adj1 field) and substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:25
10	31371	chemical near2 etching	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:19
11	669	(exchang\$5 near5 ion) and (chemical near2 etching)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:20
12	12	((("near" adj1 field) and substrate) and ((exchang\$5 near5 ion) and (chemical near2 etching))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:19
13	117	(exchang\$5 near5 ion) and (("near" adj1 field) and substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:21
14	9229	cantilever and substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/16 11:26

15	3241	(exchang\$5 near5 ion) near15 substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:04
16	17	(cantilever and substrate) and ((exchang\$5 near5 ion) near15 substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:04
17	817	(exchang\$5 near5 ion) near15 waveguide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:04
18	440	((exchang\$5 near5 ion) near15 substrate) and ((exchang\$5 near5 ion) near15 waveguide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:05
19	26898	(probe or tip) near15 substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:05
20	7	((exchang\$5 near5 ion) near15 substrate) and ((exchang\$5 near5 ion) near15 waveguide)) and ((probe or tip) near15 substrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:07
21	13	"483700"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:08
22	11	"4483700"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:28
23	770	(uv near5 radiation) and liquid	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:30
24	0	((exchang\$5 near5 ion) near15 substrate) and ((uv near5 radiation) and liquid)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:29
25	107	(uv near5 radiation) near20 substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:31
26	117941	waveguide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:30
27	1	((uv near5 radiation) near20 substrate) and waveguide	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:32
28	187	(uv near5 radiation) and (surface adj2 tension)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:40

29	51	((uv near5 radiation) near20 substrate) and ((uv near5 radiation) and (surface adj2 tension))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:32
30	770	(uv near5 radiation) and liquid	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:44
31	331975	substrate and optic\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 13:03
32	416	((uv near5 radiation) and liquid) and (substrate and optic\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:38
33	145	((uv near5 radiation) and (surface adj2 tension)) and (((uv near5 radiation) and liquid) and (substrate and optic\$5))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:39
34	80032	369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:39
35	0	((uv near5 radiation) and (surface adj2 tension)) and (((uv near5 radiation) and liquid) and (substrate and optic\$5))) and 369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:39
36	0	((uv near5 radiation) and liquid) and 369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:39
37	0	((uv near5 radiation) near20 substrate) and 369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:39
38	1226	uv near5 radiation	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 13:06
39	0	((exchang\$5 near5 ion) near15 substrate) and (uv near5 radiation)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:42
40	145	((uv near5 radiation) and (surface adj2 tension)) and (((uv near5 radiation) and liquid) and (substrate and optic\$5))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:41
41	73	waveguide and (uv near5 radiation)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 12:42
42	128	(uv near5 radiation) near25 liquid	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/04/16 13:01